

Xuelin Yang

List of Publications by Year in descending order

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103
papers

1,599
citations

304743

22
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377865

34
g-index

103
all docs

103
docs citations

103
times ranked

1805
citing authors

#	ARTICLE	IF	CITATIONS
1	High-Output Power Ultraviolet Light Source from Quasi-2D GaN Quantum Structure. <i>Advanced Materials</i> , 2016, 28, 7978-7983.	21.0	72
2	O ₃ -sourced atomic layer deposition of high quality Al ₂ O ₃ gate dielectric for normally-off GaN metal-insulator-semiconductor high-electron-mobility transistors. <i>Applied Physics Letters</i> , 2015, 106, .	3.3	58
3	High mobility AlGaIn/GaN heterostructures grown on Si substrates using a large lattice-mismatch induced stress control technology. <i>Applied Physics Letters</i> , 2015, 106, .	3.3	55
4	A review on the GaN-on-Si power electronic devices. <i>Fundamental Research</i> , 2022, 2, 462-475.	3.3	54
5	Epitaxial growth of AlN films on sapphire via a multilayer structure adopting a low- and high-temperature alternation technique. <i>CrystEngComm</i> , 2015, 17, 7496-7499.	2.6	53
6	Growth of high quality and uniformity AlGaIn/GaN heterostructures on Si substrates using a single AlGaIn layer with low Al composition. <i>Scientific Reports</i> , 2016, 6, 23020.	3.3	52
7	Identification of Helicity-Dependent Photocurrents from Topological Surface States in Bi ₂ Se ₃ Gated by Ionic Liquid. <i>Scientific Reports</i> , 2014, 4, 4889.	3.3	51
8	Epitaxy of Single-Crystalline GaN Film on CMOS-Compatible Si(100) Substrate Buffered by Graphene. <i>Advanced Functional Materials</i> , 2019, 29, 1905056.	14.9	51
9	High-temperature annealing induced evolution of strain in AlN epitaxial films grown on sapphire substrates. <i>Applied Physics Letters</i> , 2019, 114, .	3.3	51
10	Quasi-Vertical GaN Schottky Barrier Diode on Silicon Substrate With 10 ^{>10</sup> High On/Off Current Ratio and Low Specific On-Resistance. <i>IEEE Electron Device Letters</i>, 2020, 41, 329-332.}	3.9	51
11	Unambiguous Identification of Carbon Location on the N Site in Semi-insulating GaN. <i>Physical Review Letters</i> , 2018, 121, 145505.	7.8	45
12	Deep-level traps induced dark currents in extended wavelength In _x Ga _{1-x} As/InP photodetector. <i>Journal of Applied Physics</i> , 2013, 114, .	2.5	43
13	Deep Ultraviolet Light Source from Ultrathin GaN/AlN MQW Structures with Output Power Over 2 Watt. <i>Advanced Optical Materials</i> , 2019, 7, 1801763.	7.3	43
14	Study on the formation of dodecagonal pyramid on nitrogen polar GaN surface etched by hot H ₃ PO ₄ . <i>Applied Physics Letters</i> , 2009, 95, 071114.	3.3	41
15	Graphene-Assisted Epitaxy of Nitrogen Lattice Polarity GaN Films on Non-Polar Sapphire Substrates for Green Light Emitting Diodes. <i>Advanced Functional Materials</i> , 2020, 30, 2001283.	14.9	41
16	Lattice-Polarity-Driven Epitaxy of Hexagonal Semiconductor Nanowires. <i>Nano Letters</i> , 2016, 16, 1328-1334.	9.1	35
17	Structural, optical, and magnetic properties of Cu-implanted GaN films. <i>Journal of Applied Physics</i> , 2009, 105, .	2.5	31
18	High performance of AlGaIn deep-ultraviolet light emitting diodes due to improved vertical carrier transport by delta-accelerating quantum barriers. <i>Applied Physics Letters</i> , 2019, 114, .	3.3	30

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19	Revealing of the transition from n- to p-type conduction of InN:Mg by photoconductivity effect measurement. Scientific Reports, 2015, 4, 4371.	3.3	25
20	Positron annihilation in (Ga, Mn)N: A study of vacancy-type defects. Applied Physics Letters, 2009, 94, .	3.3	23
21	Al diffusion at AlN/Si interface and its suppression through substrate nitridation. Applied Physics Letters, 2020, 116, .	3.3	23
22	2.6 μm MBE grown InGaAs detectors with dark current of SRH and TAT. AIP Advances, 2014, 4, .	1.3	22
23	High-electron-mobility InN epilayers grown on silicon substrate. Applied Physics Letters, 2018, 112, .	3.3	22
24	Sub-nanometer ultrathin epitaxy of AlGa _x N and its application in efficient doping. Light: Science and Applications, 2022, 11, 71.	16.6	22
25	Experimental Evidence of Large Bandgap Energy in Atomically Thin AlN. Advanced Functional Materials, 2019, 29, 1902608.	14.9	21
26	Interface charge engineering in down-scaled AlGa _x N ($\sim 6\text{ nm}$)/Ga _x N heterostructure for fabrication of GaN-based power HEMTs and MIS-HEMTs. Applied Physics Letters, 2020, 116, .	3.3	20
27	Vacancy-engineering-induced dislocation inclination in III-nitrides on Si substrates. Physical Review Materials, 2020, 4, .	2.4	20
28	Effect of interface and bulk traps on the $\text{C}\text{-V}$ characterization of a LPCVD-Si _x N _x /AlGa _x N/GaN metal-insulator-semiconductor structure. Semiconductor Science and Technology, 2016, 31, 065014.	2.0	19
29	Lattice Polarity Manipulation of Quasi-2D Epitaxial GaN Films on Graphene Through Interface Atomic Configuration. Advanced Materials, 2022, 34, e2106814.	21.0	19
30	High-Mobility Two-Dimensional Electron Gas at InGa _x N/InN Heterointerface Grown by Molecular Beam Epitaxy. Advanced Science, 2018, 5, 1800844.	11.2	18
31	Temperature sensitive photoconductivity observed in InN layers. Applied Physics Letters, 2013, 102, .	3.3	17
32	Electronic properties of polycrystalline graphene under large local strain. Applied Physics Letters, 2014, 104, .	3.3	17
33	Positive temperature coefficient of photovoltaic efficiency in solar cells based on InGa _x N/GaN MQWs. Applied Physics Letters, 2016, 109, .	3.3	17
34	Lattice-Symmetry-Driven Epitaxy of Hierarchical GaN Nanotripods. Advanced Functional Materials, 2017, 27, 1604854.	14.9	17
35	Greatly enhanced performance of AlGa _x N-based deep ultraviolet light emitting diodes by introducing a polarization modulated electron blocking layer. Optics Express, 2019, 27, A1458.	3.4	17
36	Controlled bunching approach for achieving high efficiency active region in AlGa _x N-based deep ultraviolet light-emitting devices with dual-band emission. Applied Physics Letters, 2020, 116, .	3.3	16

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37	Thermally annealed wafer-scale h-BN films grown on sapphire substrate by molecular beam epitaxy. Applied Physics Letters, 2020, 116, .	3.3	16
38	Exciton emission of quasi-2D InGaN in GaN matrix grown by molecular beam epitaxy. Scientific Reports, 2017, 7, 46420.	3.3	14
39	Realization of high efficiency AlGaIn-based multiple quantum wells grown on nano-patterned sapphire substrates. CrystEngComm, 2021, 23, 1201-1206.	2.6	14
40	Stress evolution in AlN growth on nano-patterned sapphire substrates. Applied Physics Express, 2020, 13, 015504.	2.4	13
41	High quality AlN film grown on a nano-concave-circle patterned Si substrate with an AlN seed layer. Applied Physics Letters, 2020, 117, .	3.3	13
42	Luminescent properties in the strain adjusted phosphor-free GaN based white light-emitting diode. Applied Physics Letters, 2008, 93, .	3.3	12
43	Period size effect induced crystalline quality improvement of AlN on a nano-patterned sapphire substrate. Japanese Journal of Applied Physics, 2019, 58, 100912.	1.5	12
44	Direct evidence of hydrogen interaction with carbon: C-H complex in semi-insulating GaN. Applied Physics Letters, 2020, 116, .	3.3	12
45	High quality GaN-on-SiC with low thermal boundary resistance by employing an ultrathin AlGaIn buffer layer. Applied Physics Letters, 2021, 118, .	3.3	12
46	Enhanced transport properties in InAlGaIn/AlN/GaN heterostructures on Si (111) substrates: The role of interface quality. Applied Physics Letters, 2017, 110, .	3.3	11
47	Three Subband Occupation of the Two-Dimensional Electron Gas in Ultrathin Barrier AlN/GaN Heterostructures. Advanced Functional Materials, 2020, 30, 2004450.	14.9	11
48	Strain-enhanced high Q -factor GaN micro-electromechanical resonator. Science and Technology of Advanced Materials, 2020, 21, 515-523.	6.1	11
49	Control of dislocations in heteroepitaxial AlN films by extrinsic supersaturated vacancies introduced through thermal desorption of heteroatoms. Applied Physics Letters, 2021, 118, .	3.3	11
50	Formation of p-n-p junction with ionic liquid gate in graphene. Applied Physics Letters, 2014, 104, .	3.3	10
51	AlGaIn/GaN pressure sensor with a Wheatstone bridge structure. AIP Advances, 2018, 8, .	1.3	10
52	Improved Ohmic contacts to plasma etched high Al fraction n-AlGaIn by active surface pretreatment. Applied Physics Letters, 2021, 118, .	3.3	10
53	Temperature-dependent polarization characteristics in Al _{0.25} Ga _{0.75} N/AlN/GaN heterostructure. Applied Physics Letters, 2016, 108, .	3.3	9
54	Vertical leakage induced current degradation and relevant traps with large lattice relaxation in AlGaIn/GaN heterostructures on Si. Applied Physics Letters, 2018, 112, 032104.	3.3	8

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73	High-mobility n^+ -GaN drift layer grown on Si substrates. Applied Physics Letters, 2021, 118, .	3.3	5
74	Anisotropic strain relaxation and high quality AlGaIn/GaN heterostructures on Si (110) substrates. Applied Physics Letters, 2017, 110, .	3.3	5
75	Direct observation of room-temperature ferromagnetism of single-phase Ga _{0.962} Mn _{0.038} N by magnetic force microscopy. Journal of Applied Physics, 2010, 108, 093913.	2.5	4
76	Effects of light illumination on electron velocity of AlGaIn/GaN heterostructures under high electric field. Applied Physics Letters, 2014, 105, 242104.	3.3	4
77	Hot electron assisted vertical leakage/breakdown in AlGaIn/GaN heterostructures on Si substrates. Superlattices and Microstructures, 2017, 107, 240-245.	3.1	4
78	Role of hole trapping in the unintentionally doped GaN layer in suppressing the two-dimensional electron gas degradation in AlGaIn/GaN heterostructures on Si. Nanotechnology, 2019, 30, 314002.	2.6	4
79	Carrier Velocity Modulation by Asymmetrical Concave Quantum Barriers to Improve the Performance of AlGaIn-Based Deep Ultraviolet Light Emitting Diodes. IEEE Photonics Journal, 2021, 13, 1-8.	2.0	4
80	High quality AlN with uniform in-plane strain on nano-patterned AlN templates achieved by preset strain modulation. Japanese Journal of Applied Physics, 2021, 60, 120903.	1.5	4
81	GaN HEMTs on low resistivity Si substrates with thick buffer layers for RF signal amplification and power conversion. AIP Advances, 2022, 12, .	1.3	4
82	Evolution of traps in TiN/O ₃ -sourced Al ₂ O ₃ /GaN gate structures with thermal annealing temperature. Journal of Vacuum Science and Technology B: Nanotechnology and Microelectronics, 2018, 36, 022202.	1.2	3
83	Impact of Silicon Substrate with Low Resistivity on Vertical Leakage Current in AlGaIn/GaN HEMTs. Applied Sciences (Switzerland), 2019, 9, 2373.	2.5	3
84	High-pressure MOCVD growth of InGaIn thick films toward the photovoltaic applications. Fundamental Research, 2023, 3, 403-408.	3.3	3
85	Low RF loss and low dislocation density of GaN grown on high-resistivity Si substrates. Applied Physics Express, 2022, 15, 031003.	2.4	3
86	High-Performance Quasi-Vertical GaN Schottky Barrier Diode on Silicon Substrate with a Low Dislocation Density Drift Layer. , 2019, , .		2
87	Infrared stimulated emission with an ultralow threshold from low-dislocation-density InN films grown on a vicinal GaN substrate. Fundamental Research, 2022, 2, 794-798.	3.3	2
88	Influence of intrinsic or extrinsic doping on charge state of carbon and its interaction with hydrogen in GaN. Applied Physics Letters, 2022, 120, .	3.3	2
89	Low-Resistive Ohmic Contacts in High-Electron-Mobility AlN/GaN Heterostructures by Suppressing the Oxygen Incorporation. ACS Applied Electronic Materials, 2022, 4, 3632-3639.	4.3	2
90	Mechanism of ultrahigh Mn concentration in epitaxially grown wurtzite Ga _{1-x} Mn _x N. Applied Physics Letters, 2010, 97, 222108.	3.3	1

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91	Influence of Si co-doping on magnetic, electrical and optical properties of Ga _{1-x} Mn _x N film grown by MOCVD. Science China Technological Sciences, 2011, 54, 1703-1707.	4.0	1
92	Fluorine plasma treatment induced deep level traps and their effect on current transportation in Al _{0.83} In _{0.17} N/AlN/GaN Schottky barrier diodes. Journal Physics D: Applied Physics, 2016, 49, 305103.	2.8	1
93	Enhanced Hydrogen Detection Based on Mg-Doped InN Epilayer. Sensors, 2018, 18, 2065.	3.8	1
94	GaN on Si(100): Epitaxy of Single-Crystalline GaN Film on CMOS-Compatible Si(100) Substrate Buffered by Graphene (Adv. Funct. Mater. 42/2019). Advanced Functional Materials, 2019, 29, 1970293.	14.9	1
95	The effect of kink and vertical leakage mechanisms in GaN-on-Si epitaxial layers. Semiconductor Science and Technology, 2020, 35, 085015.	2.0	1
96	Elastic strain engineered nanomechanical GaN resonators with thermoelastic dissipation dilution up to 600%K. Journal of Applied Physics, 2022, 131, .	2.5	1
97	Accurate characterization of room-temperature long range magnetic order in GaN: Mn by magnetic force microscope. Science China Technological Sciences, 2011, 54, 15-18.	4.0	0
98	Magnetotransport properties of high equivalent Al composition AlGa _N /Ga _N heterostructures using AlN/GaN superlattice as a barrier. Journal of Applied Physics, 2013, 114, .	2.5	0
99	Influence of barrier thickness on luminescence lifetime of the two-dimensional electron gas in InAlN/GaN heterostructures. Superlattices and Microstructures, 2017, 106, 170-173.	3.1	0
100	Direct-readout pressure sensor based on AlGa _N /Ga _N heterostructure. Microsystem Technologies, 2020, 26, 3189-3192.	2.0	0
101	Lattice Polarity Manipulation of Quasi-vdW Epitaxial GaN Films on Graphene Through Interface Atomic Configuration (Adv. Mater. 5/2022). Advanced Materials, 2022, 34, .	21.0	0
102	Polarization-Driven Orientation Selective Growth of Single-Crystalline III-Nitride Semiconductors on Arbitrary Substrates (Adv. Funct. Mater. 14/2022). Advanced Functional Materials, 2022, 32, .	14.9	0
103	Low radio frequency loss and buffer-free GaN directly on physical-vapor-deposition AlN/Si templates. Applied Physics Express, 2022, 15, 081001.	2.4	0